

CITATIONS:

A: Citations of Papers Published From 2002 to Date (Excluded Self-Citations)

Source Paper: JP25. Durrani S.M.A., Khawaja E.E., Salim M.A., Al-Kuhaili M.F., and Al-Shukri A.M.
“Effect of preparation conditions on the optical and thermochromic properties of thin films of tungsten oxide”.
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2. Joraid, A.A., Alamri, S.N.
“Effect of annealing on structural and optical properties of WO₃ thin films prepared by electron-beam coating”
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4. Niklasson, G.A., Granqvist, C.G.
“Electrochromics for smart windows: Thin films of tungsten oxide and nickel oxide, and devices based on these”
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5. Deepa M, Singh P, Sharma SN, et al.
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11. Soto G, De la Cruz W, Diaz JA, et al.
“Characterization of tungsten oxide films produced by reactive pulsed laser deposition”
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“Dopant-dependent reflectivity and refractive index of microcrystalline H_xWO₃ and Li_xWO₃ bronze thin films”
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Source Paper: JP26 Al-Kuhaili M. F., Durrani S.M.A. and Khawaja E.E.
“Effects of preparation conditions on the optical and thermocoloration properties of thin films of molybdenum oxide”
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Citations:

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“Thin film deposition, patterning, and printing in organic thin film transistors”
Chemistry of Materials 16 (23), pp. 4824-4840 (2004)

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Energy and Buildings, Vol. 36(2004), pp 891-898

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